REPORT DOCUMENTATION PAGE

Form Approved OMB No. 0704-0188

Public reporting burden for this collection of information is estimated to average 1 hour per response, including the time for reviewing instructions, searching data sources, gathering and maintaining the data peeded and completing and reviewing the collection of information is estimated to average 1 hour per response, including the time for reviewing instructions, searching data sources,

1215 Jefferson Davis	Highway, Suite 120	4, Arlington, VA 22202	Washington Headquarters Service 2-4302, and to the Office of Manager	e, Directorate for Infor gement and Budget,	rmation Operatio	burden estimate or any other aspect of this collection ns and Reports,
PLEASE DO NO	T RETURN Y	OUR FORM TO	^{03.} THE ABOVE ADDRESS) .		
1. REPORT DAT 1006-20			EPORT DATE			3. DATES COVERED (From - To)
	_	T	echnical			19-06-2000 to 20-06-2001
4. TITLE AND S				-	5a. COI	NTRACT NUMBER
Solid-St	ate Tera	hertz Sou	rces			
					5b. GR	ANT NUMBER
					l _{NO}	0014-99-1-0915
						OGRAM ELEMENT NUMBER
					JU. FIN	JORAM ELEMEN! NUMBER
6. AUTHOR(S) Dimitris Pavlidis, Linda Katehi and Jack East					5d. PRO	DJECT NUMBER
					م ا	PRO7316-00
	•	- ,		K Last		K NUMBER
						TO T
					= 1405	
					51. WUF	RK UNIT NUMBER
7. PERFORMING	ORGANIZAT	ION NAME(S) A	ND ADDRESS(ES)			8. PERFORMING ORGANIZATION
University of Michigan						REPORT NUMBER
Electrical Engineering and Computer Science						
1301 Bea	1 Ave 230)7 EECS	. Computer bure	ance		
Ann Arbo	r MI 4810	9-2122				1
9. SPONSORING	MONITORIN	G AGENCY NAM	ME(S) AND ADDRESS(E	:S)		10. SPONSOR/MONITOR'S ACRONYM(S)
DIS	ודו וםוםד	~~. ~~.~~				
Dio An		ON STATE	MENTA			
wh	proved to	or Public R	lelease			11. SPONSORING/MONITORING
	Distribut	ion Unlim	ted			AGENCY REPORT NUMBER
12. DISTRIBUTIO	ON AVAILABIL	ITY STATEMEN	T			
		, hier				
13. SUPPLEMEN	TABY NOTES				フロ	010712 026
13. SUFFLEINEN	IIAKT NUTES	i			_ <u> </u>	יטוטווב טבס
						
14. ABSTRACT						
GaN Trans	ferred E	lectron De	evices (TEDs)	have been	invect	igated on SiC substrates.
DIO CHITHH	rng and	via-noie i	cechnology hav	e been der	veloned	and annited to Con TED. f
rmbrosed	berrorma	nce. Low-1	cemperature te	sts have l	heen co	nducted for bottom
understan	ding of	velocity-	field characte	ristics. I	Daggivo	micromachined circuitry
has been	investig	ated and o	leen etched we	rtical wa	11 0+	ctures were explored.
Micromach	ined-to-	waveouide	transitions h	reitar was	tr Stra	ctures were explored. ted and a test circuit for
a microma	chined w	evecuide t	o nlanar circ	ave neem m	Tabrica	ted and a test circuit for
- mileronia	d at W-b	and.	o pranar circ	air brone	has be	en designed, fabricated,
and teste		and.				
and teste					_	
and teste	RMS	conductor	Devices. Inte	rated Cir	conite	Tree toward and done
and teste	RMS Semi	conductor frequencie	Devices, Integ	grated Cir	cuits,	Two terminal devices,
and teste	RMS Semi	conductor frequencie	Devices, Inte	grated Cir	cuits,	Two terminal devices,
5. SUBJECT TE	RMS Semio THz	requencie	.s.			
5. SUBJECT TE	RMS Semion THz	N OF:	Devices, Interes. 17. LIMITATION OF ABSTRACT		19a. NAME (DF RESPONSIBLE PERSON
5. SUBJECT TE	RMS Semio THz	requencie	17. LIMITATION OF	18. NUMBER OF PAGES	19a. NAME O	

Progress Report: DARPA THz Project

Dimitris Pavlidis, Jack East and Linda Katehi
The University of Michigan
Department of Electrical Engineering
and Computer Science
1301 Beal Ave.
Ann Arbor ,MI 48109-2122
Tel:(734) 647-1778 , Fax:(734) 763-9324
e-mail: pavlidis@umich.edu, URL: www.eecs.umich.edu/dp-group

June 10, 2001

This project focuses on the development of GaN Transferred Electron Devices and micromachined circuits.

In the area of GaN Transferred Electron Devices we have been working on the following

Major effort was placed on the development and optimization of all the critical processing steps necessary for producing GaN-based Transferred Electron Devices. The include SiC wafer thinning, separation of fabricated diodes into discrete chips, mounting into cavities and etching of via holes for backside processing.

Lapping technology for SiC wafers has been set up and a lapping rate of ~50µm/hour has been achieved using BC powder. SiC wafers of ~350µm initial thickness have been successfully thinned down to ~50µm. Electrical testing of GaN devices after thinning revealed no degradation of electrical characteristics, including MMIC devices with pre-fabricated airbridges. We have attempted to use a scribing tool to separate the thinned GaN diode wafers into discrete chips but breaking took place along the hexagonal direction. Use of a trimming laser technique was also attempted. Ultra thin diamond blades have been used and allowed dicing of the GaN diodes. We have interacted with a Gunn diode company regarding diode packaging and have prepared samples for mounting at their facility. The devices prepared will be placed in packages that are compatible with cavity resonators.

In view of a complementary characterization of transport properties in GaN materials we have interacted with the Army Research Laboratory and determined a structure, which could be adapted to their measurement system and employs Schottky rather than p-n junction design.

Using SiC substrates with high thermal conductivity allowed us to bias GaN Gunn diodes under very high power conditions. However, the estimated value of the electric field within the active region for this devices was still lower (125KV/cm) than the threshold field, estimated by experimental techniques i.e. ARL (200KV/cm). By cooling the device down to 170K in the cryogenic chamber we have obtained for the first time a very promising pulsed I-V characteristic which showed a definite current saturation at a voltage of ~23V and a current of ~2.2A.

We have designed GaN diodes with AlGaN launchers to study the impact of heterostructure launching on the dead zone and efficiency of operation. Layers of this type were grown by MOCVD and are currently processed.

The design of a planar Gunn oscillator has been initiated in collaboration with Linz University that pioneered this approach. This GaN Gunn circuit will allow to perform a comparative study of operation with the original vertical approach in terms of transport and thermal effects.

In the area of micromachined components for THz circuits we have been working on the following:

Passive micromachined circuits have been investigated for THz applications. We have three ongoing projects under the program. The first project is the development of microwave machined waveguides for high frequency applications. Hopefully these will replace difficult to machine conventional waveguides. We have optimized a deep etch process to fabricate vertical wall structures. This process have been used to fabricate prototype WR3 waveguides for operation between 220 and 325 GHz. We have also designed and fabricated WR3 tunable shorts. Typical micromachined structures are sometimes difficult to characterize. We have fabricated waveguide flanges to allow connection between the micromachined circuits and existing measurement systems. These WR3 circuits are ready for measurements.

The second project is a complete micromachined waveguide to planar circuit probe. This structure will allow integration of semiconductor devices with micromachined structures. A test circuit has been designed, fabricated and RF tested in W band with excellent results. Finally, we have started on the design of a micromachined THz power combiner. This circuit will combine waveguides, tuning elements, transitions and antennas in a single circuit as a test structure for more complex circuits. The initial design work on this structure has started.

Recent Publications

- 1. E. Alekseev and D. Pavlidis, GaN-based Gunn Diodes: Their Frequency and Power Performance and Experimental Considerations, Topical Workshop on Heterostructure Microelectronics, Kyoto, Japan, August 20 to 23, 2000, pp. 46-47
- 2. A.K. Panda, D. Pavlidis, E. Alekseev, DC and High-Frequency Characteristics of GaN-based IMPATTs, To appear in: IEEE Transactions on Electron Devices
- 3. A.K. Panda, D. Pavlidis, E. Alekseev, Noise Characteristics of GaN-based IMPATTs, To appear in IEEE Transactions on Electron Devices
- 4. E. Alekseev, D. Pavlidis, W. E. Sutton, E. Piner and J. Redwing, GaN-based Gunn Diodes: Their Frequency, Power Performance and Experimental Considerations, Submitted to the Journal of the Institute of Electronics and Information and Communication Engineers (IEICE), Japan
- 5. James P. Becker, Yongshik Lee, Jack R. East and Linda P.B. Katehi, "A Fully Packaged Finite-Ground Coplanar Line-To-Silicon Micromachined Waveguide Transition," Proceedings of IEEE 9th Topical Meeting on Electrical Performance of Electronic Packaging, Oct 2000. IEEE#00TH8524, pp. 273-276
- 6. James P. Becker, Yongshik Lee, Jack R. East and Linda P.B. Katehi, "A Finite Ground Coplanar Line-To-Silicon Micromachined Waveguide Transition, submitted to IEEE Transactions on Microwave Theory and Techniques, Special Issue.